

#### First test of a diamond detector at European XFEL

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## Facility Layout (photon part)



# FEL beam properties (SASE1 and SASE2 undulators)





Example of three adjacent FEL pulses – each pulse can have different LASER modes (after monochromator)

# X-ray photon diagnostics at European XFEL

Measurement of beam properties

- Invasive diagnostics (Imagers, MCP detector, K-mono, ...)
- Gas based online diagnostics
  - XGM (X-ray Gas Monitor), main instrument for pulse energy and avg. beam position
  - PES (Photoelectron spectrometer, 16 TOF)
- Solid-state online diagnostics (minimally invasive)
  - Single-shot spectrometer (HIREX)
  - **Backscatter monitors**
  - **Diamond screens**
  - **Diamond detectors**



Filter Ch. & IMGTR



K-mono





**HIREX** single shot spectrometer







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## **Diamond detectors for X-ray photon diagnostics**

First diamond detector projects started already in 2012 with tests at Elettra and LCLS (\*). We are now relaunching the detector project. The goal is to build a detector setup for single-shot intensity and position detection in the hard-X-ray beamlines.

#### **Requirements:**

High pulse energy  $\rightarrow$  radiation hard and robust against single shot damage

- High repetition rate (4.5MHz)  $\rightarrow$  detector speed
- Beam position jitter  $\rightarrow$  measurement accuracy between 10 and 100 µm (depending on position)
- Intensity jitter  $\rightarrow$  relative accuracy better 1% and high dynamic range
- Continually in beam path  $\rightarrow$  minimal interference with beam
- $\blacksquare$  e.g. use ins split and delay units for adjustment of beam path ightarrow small detector
- Fast feedback to accelerator  $\rightarrow$  pulse resolved detector

<sup>(\*)</sup> Roth, T., Freund, W., Boesenberg, U., Carini, G., Song, S., Lefeuvre, G., Goikhman, A., Fischer, M., Schreck, M., Grünert, J. & Madsen, A. (2018). J. Synchrotron Rad. 25, 177-188.

#### **Duolateral diamond detector**

#### Detector fabricated at CEA Saclay (M. Pomorski)



Images courtesy M. Pomorski

Ref: M.Pomorski et al., Phys. Status Solidi A 206, No. 9, 2109–2114 (2009) / DOI 10.1002/pssa.200982229

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### **Detector assembly**

Tested diamond sample EG-6 processed by Michal Pomorski, CEA (40 µm single crystal CVD, electronic grade)

DLC layer: surface resistance of 350  $\Omega$  and 750  $\Omega$ 

Al contacts at the edges

 Why using a duo-lateral and not a four-quadrant detector ?
 SASE-FEL strongly jitters in energy, position, shape: non-gaussian beam with large deviation from the center → no reliable measurement (4-quadrant)
 FEL is highly coherent: non-homogenous contacts introduce wavefront distortion (probably pure carbon contacts could be used)





### **Measurement setup**

Beam parameters:

- 9.3 keV x-rays
- max. 1.1 mJ per pulse (~ 7\*10<sup>11</sup> photons)
- Pulse length ~ 50 fs
- 4.5 MHz repetition rate
- Beam diameter approx. 1- 2 mm (not focused)

#### Setup:

- Fast oscilloscope (50 GS/s) or ADC board (108 MS/s) with pulse stretcher
- Up to 30 dB attenuators at the 50 Ohm inputs no amplifiers







#### **Measurements**

MID instrument in SASE2 (Materials Imaging & Dynamics)

Commissioning beamtimes:
 February 2019 with 7.5 keV / 30 µJ beam before first user run, beam was not stable, test of instrumentation
 July 2019 with 9.3 keV / 1.2 mJ beam good beam conditions, DAQ problems

Difficult to get fully supported user beamtimes for our detector development

#### Pulse shape at low intensity

Beam condition: 7.5 keV, 30 µJ, repetition rate 1.1 MHz

Detector directly connected to oscilloscope, signal from front side

Best timing with 30-50 V bias



### Pulse shape at low intensity

- Beam conditions and setup as before
- Signal readout via bias-Tee from backside
- Similar signal as before, but some overshoot after the main peak  $\rightarrow$  optimization of electronics



## Pulse shape at high intensity / high rep-rate

Measured signal vs bias voltage

9.3 keV, 1.1 mJ, 2 bunches@ 4.5 MHz



Diamond BPM channel Top with Bias-T

## Pulse shape at high intensity / high rep-rate



## **Conclusions and outlook**

Detectors worked well at low pulse energy. Saturation effects at higher intensity (> 100 μJ).

- Need faster detectors:
  - Lower surface resistance of electrodes (may compromise position accuracy)
  - Test of four-quadrant detector with carbon electrodes
  - Thin detectors ~ 10 µm
- Diamond detectors could be used for beam stability high speed feedback systems
- Need a small series of detectors for MID split-and-delay-unit, which must be compact and UHV compatible (e)

   b2
   b1

   upper branch
   upper branch





### Thank you for your attention

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## **SPARE SLIDES**



## **Measurements at LCLS from 2013**

#### 📒 50 μm diamond



# **Measurements at LCLS from 2013**

1D-position scans / moved DD on x-y-stage in x-direction

- 300 μm diamond
   3.4 kΩ/8.2 kΩ
- 3 different x-positions
- Slits: 100 x 100 µm
- Attenuation: 10<sup>-2</sup> (transm.)
- Bias: +200 V at front
- Single shot data
- Averaged position accuracy better 5 μm



## **Measurements at LCLS from 2013**

1D-position scans / moved DD on x-y-stage in x-direction

300 µm diamond 0.2 0.1 5 µm stepwidth / 1mm range 0 Slits: 100 x 100 µm (CH1-CH2)/(CH1+CH2)\*L<sub>def</sub>/2 -0.1 Attenuation: 10<sup>-2</sup> (transm.) -0.2 Bias: +200 V at front -0.3 Average of 1000 shots/step -0.4 -0.5 -0.6 -0.7 -0.8 0.2 0.4 1.2 0.6 0.8 1.4 1.6 Detector x position (mm)